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(12) **United States Design Patent**  
**Ota et al.**

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(45) **Date of Patent:** **\*\* Jul. 8, 2008**

(54) **TOP PANEL FOR MICROWAVE  
INTRODUCTION WINDOW OF A PLASMA  
PROCESSING APPARATUS**

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(51) **LOC (8) Cl.** ..... **15-09**

(52) **U.S. Cl.** ..... **D15/138; D15/199**

(58) **Field of Classification Search** ..... D7/586,  
D7/587, 501, 553.6, 600.4; D8/70, 74; D9/445,  
D9/454, 456; D15/133, 144.1, 199, 122,  
D15/138, 139; 117/103; 118/723 AN, 723 ME,  
118/723 MP, 723 MW, 723 E, 723 ER; 216/69,  
216/67; 257/E21.252, 629, 631, E39.001;  
427/562, 571, 575; D1/126, 128; D6/455;  
D13/122, 138, 139, 157-177, 182; D18/17;  
156/242, 345; 175/374, 434; 204/298.38;  
219/420-424, 523, 530, 541, 544; 264/328.14,  
264/328.15, 328.16; 313/231.31; 315/111.21;  
407/113-118; 408/145; 425/547-550, 564,  
425/566, 570; 451/540-548; 700/121, 123

See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a top panel for microwave intro-  
duction window of a plasma processing apparatus, as shown  
and described.

**DESCRIPTION**

FIG. 1 is a front view of a top panel for microwave introduc-  
tion window of a plasma processing apparatus showing our  
new design;

FIG. 2 is a rear view thereof;

FIG. 3 is a right side view thereof;

FIG. 4 is a left side view thereof;

FIG. 5 is a top plan view thereof;

FIG. 6 is a bottom plan view thereof;

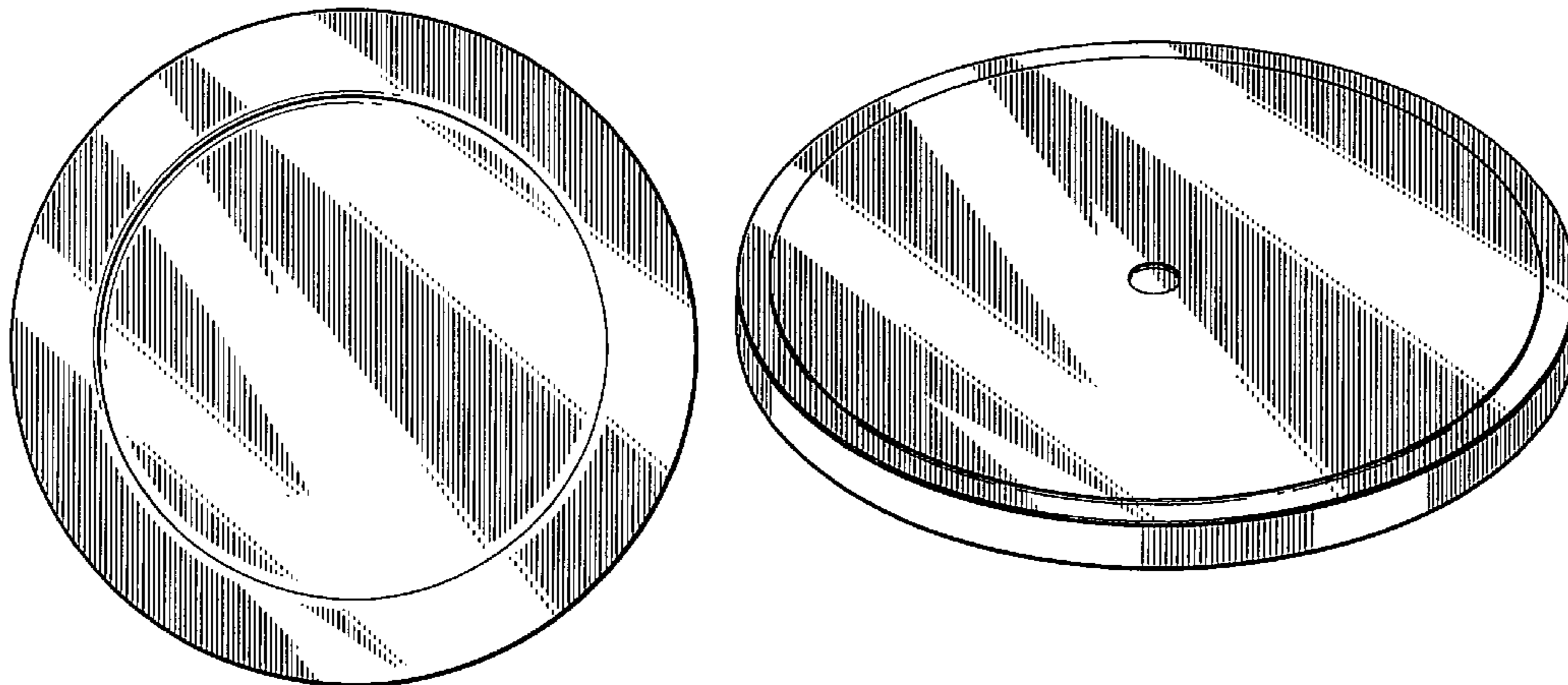
FIG. 7 is a sectional view taken along line 7—7 of FIG. 5;

FIG. 8 is an enlarged view taken along line 8—8 of FIG. 7;

FIG. 9 is an enlarged view taken along line 9—9 of FIG. 7;  
and,

FIG. 10 is a perspective view thereof.

**1 Claim, 4 Drawing Sheets**



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FIG. 1



FIG. 2



FIG. 3



FIG. 4



FIG.5

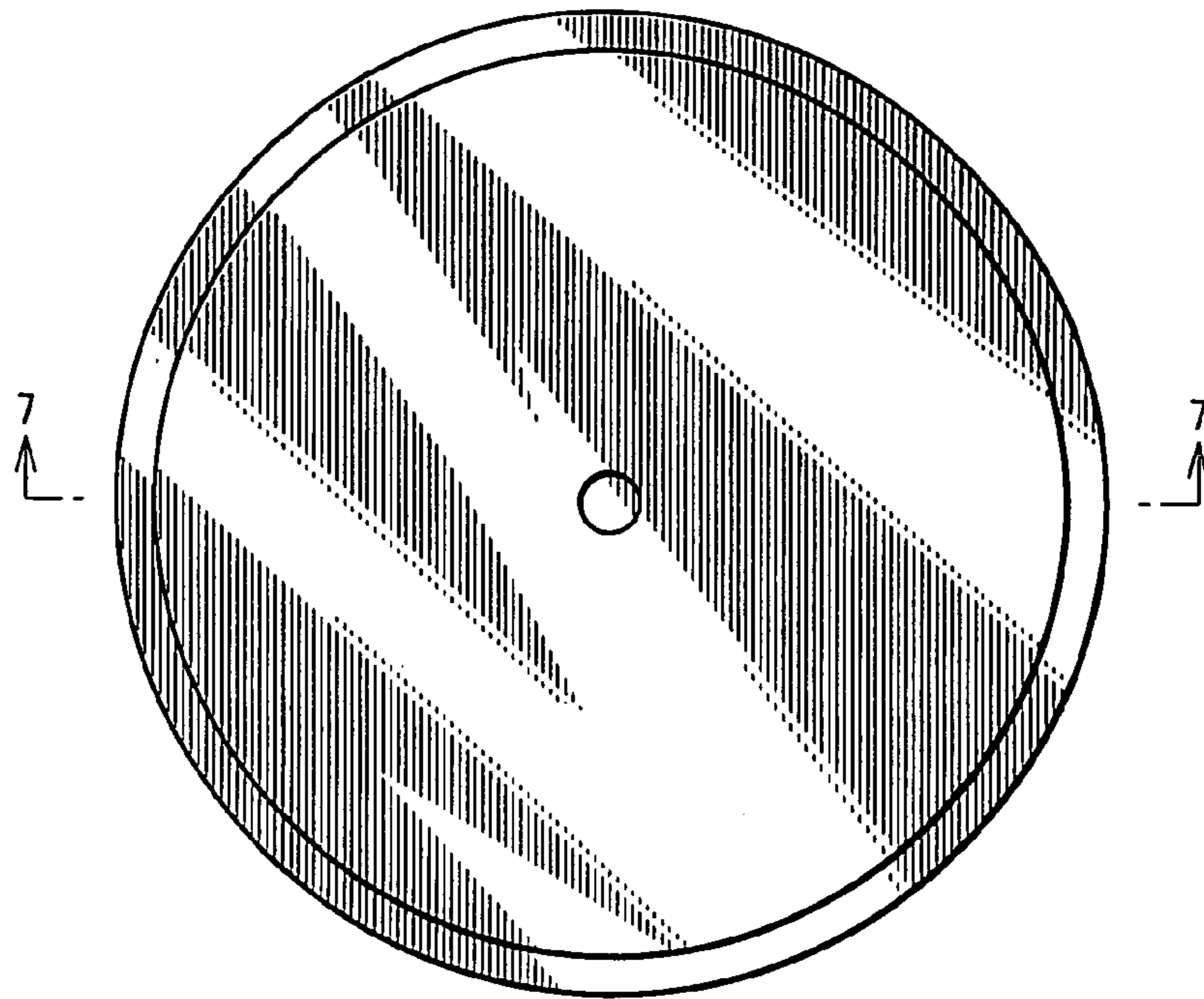


FIG.6

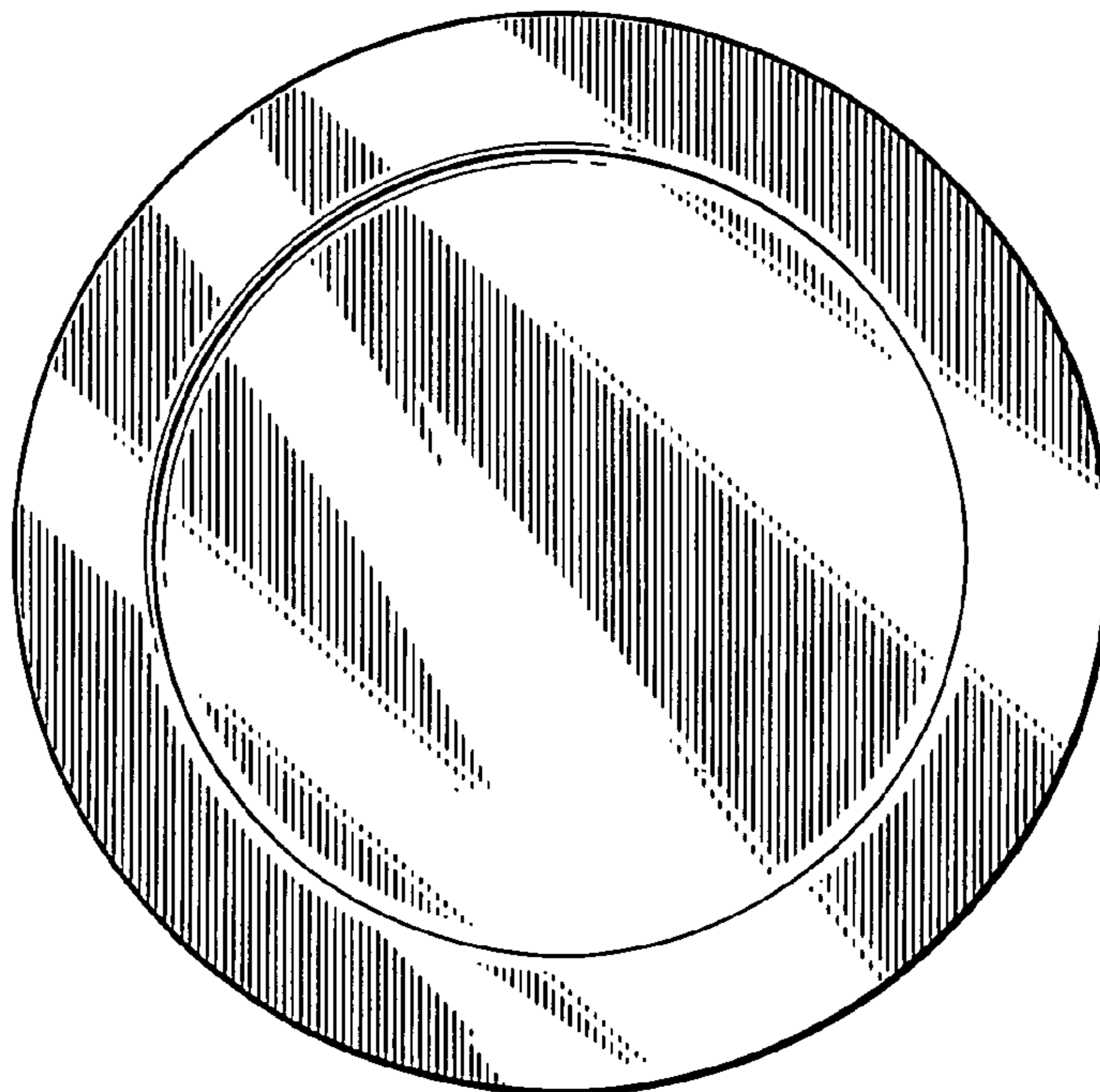


FIG.7

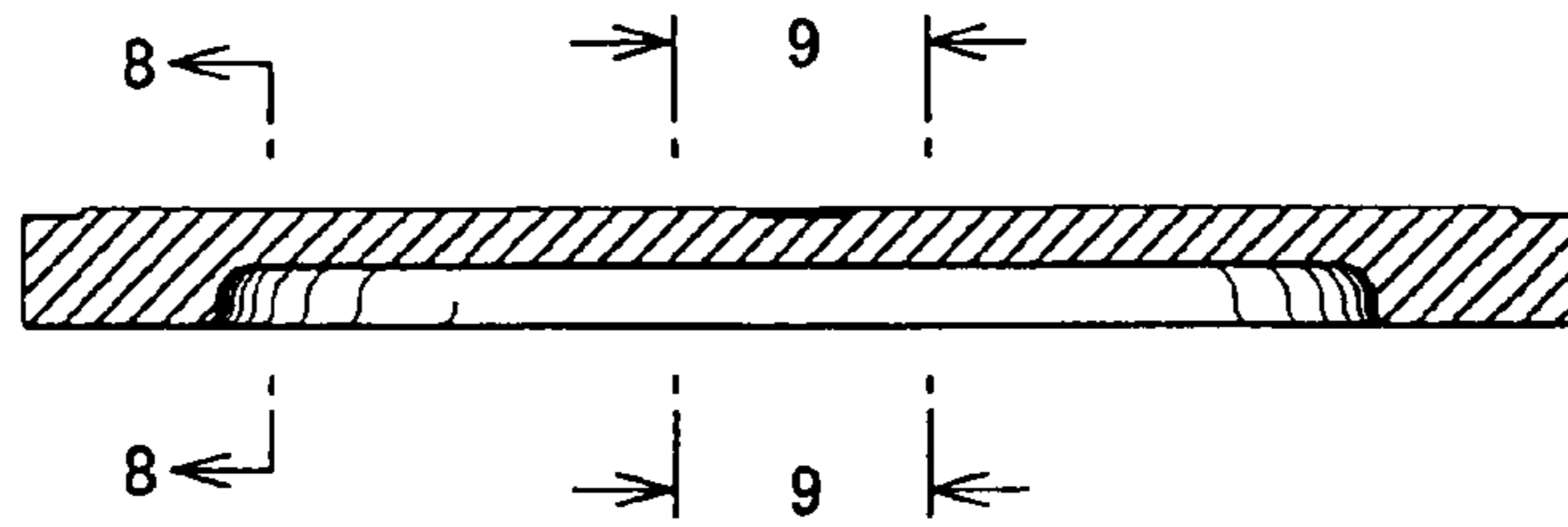


FIG.8

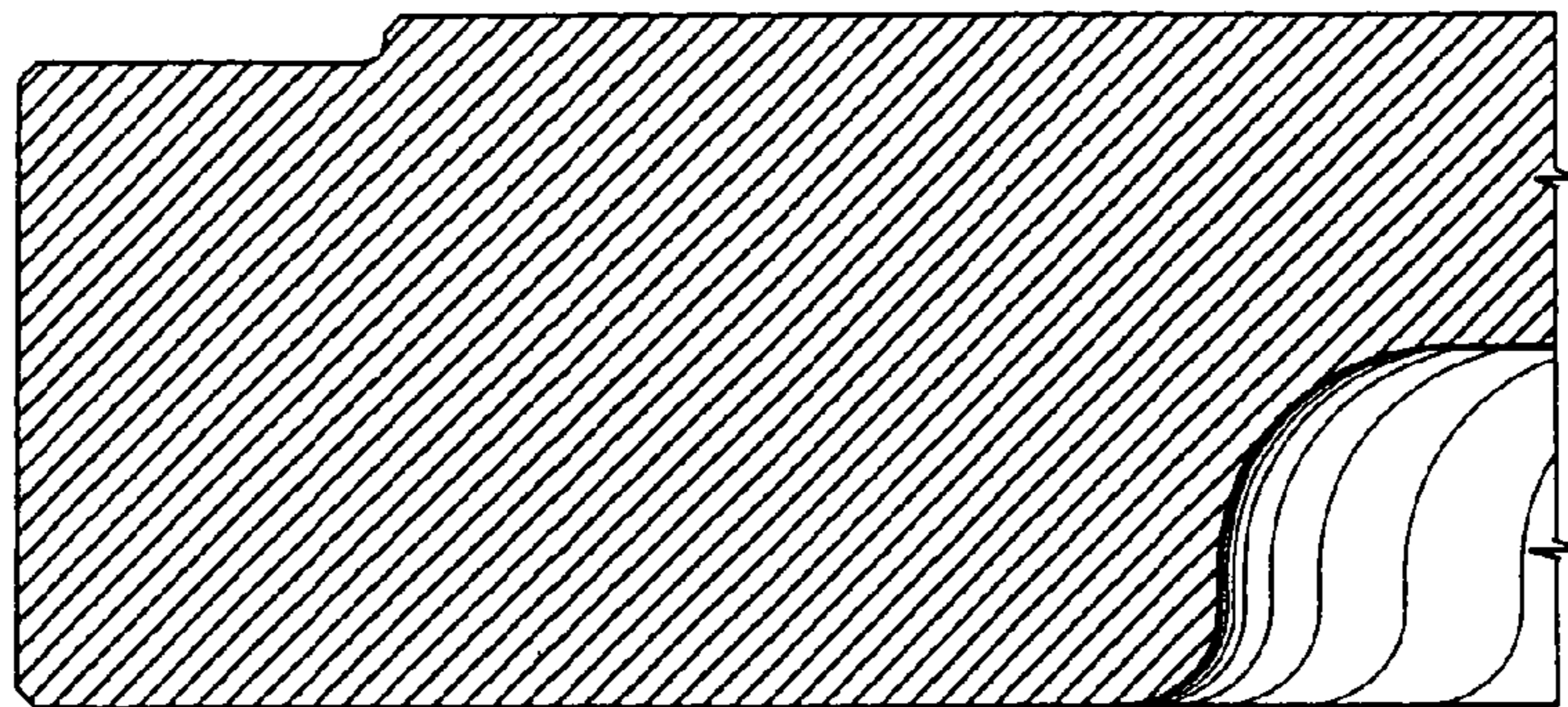


FIG.9

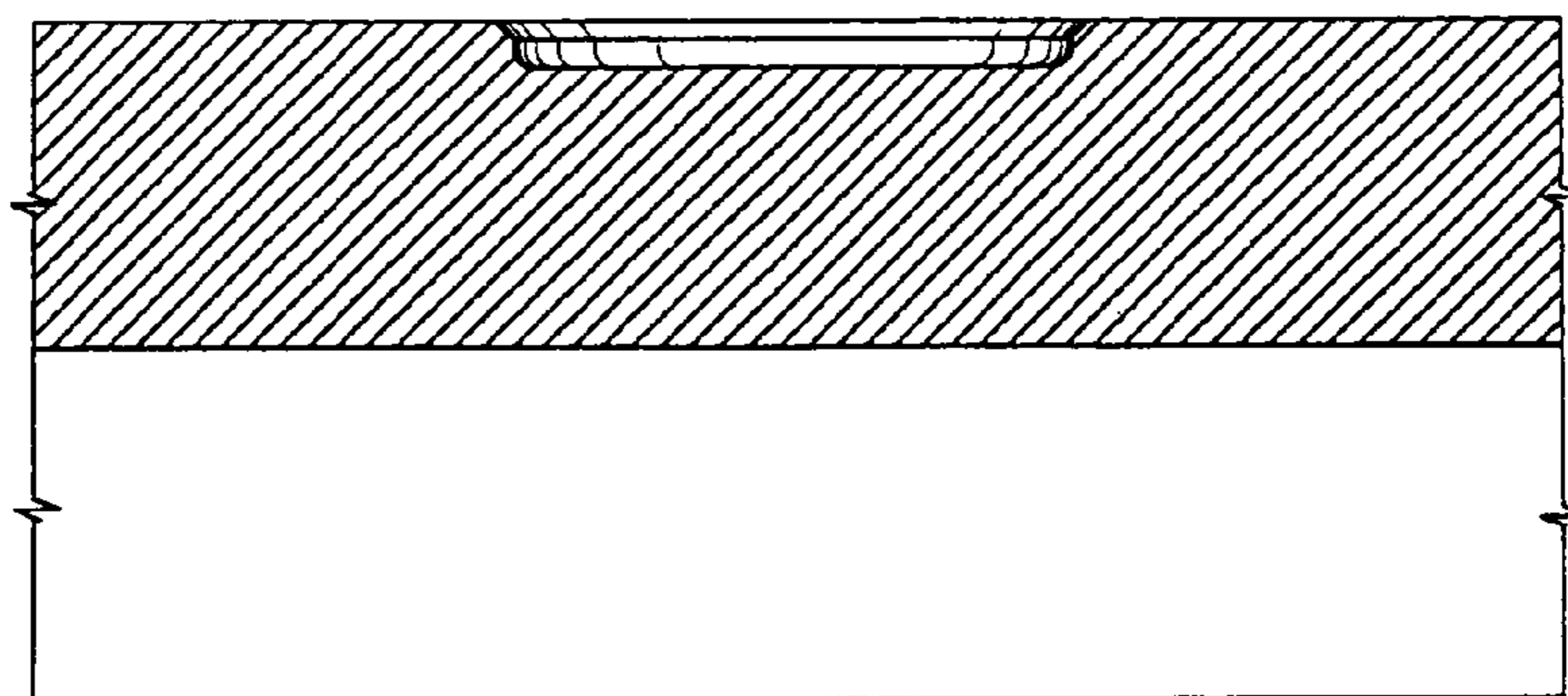


FIG.10

